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IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

Applicant: SEOK-YOON YANG, ET AL.)
Serial No.: 10/675,455) Group Art Unit:
Filed: September 30, 2003) 1752
For: PHOTSENSITIVE RESIN COMPOSITION)
CONTROLLING SOLUBILITY AND PATTERN)
FORMATION METHOD OF DOUBLE-LAYER)
STRUCTURE USING THE SAME)

AMENDMENT

Commissioner for Patents
P.O. Box 1450
Alexandria, VA 22313-1450

Sir,

This amendment is being filed in response to the office action dated July 13, 2005.
An extension of time for 1 month is hereby enclosed as well. Please amend the application
as follows:

11/15/2005 ZJUHA1 00000029 061130 10675455
01 FC:1251 120.00 DA

OPP021264US/YOM-0062

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